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Analysis of Microinductor Performance in a 20–100 MHz DC/DC Converter

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Abstract—This paper presents a low-profile thin-film microfabricated inductor on silicon and its performance in a high-frequency low-power dc/dc converter. The design of the inductors has focused on maximizing efficiency while maintaining a relatively flat frequency response up to 30 MHz. The inductance at 20 MHz is approximately 150 nH with a resistance of 1.8 Ω . The performance of the microinductor has been compared to two conventional commercially available 150-nH chip inductors. One of the chip inductors has a magnetic-material core and the other is an air core. The maximum efficiency of the microinductor, which relates the power loss of the microinductor to output power loss of the converter, is measured to be approximately 93% at 20 MHz. The low-power dc/dc converter operates in the tens of milliwatts output power range, with an input voltage of 1.8 V and an output voltage programmable between 0 and 1.8 V. The converter maximum efficiency when using the microinductor on silicon is 78.5% at 20 MHz, which is approximately 2% lower than the efficiency using the conventional chip inductors.

Index Terms—DC/DC conversion, high frequency, low profile, magnetic-core inductors.

I. INTRODUCTION

T HE INCREASE in functionality and size reduction of portable electronic products is driving the requirement for miniaturization and integration of low-power dc/dc converters. The integration of the passive components has so far retarded progress toward monolithic integration of the converter. Passive component integration has been difficult due to the fact that high converter switching frequencies are required to reduce passive values, and hence size, to the point where integration on-chip or in-package becomes feasible. However, with the advances in semiconductor technology, the implementation of high-efficiency, high-frequency active devices has become feasible. For example, recent research activities within several semiconductor companies have suggested that dc/dc down-converter switching frequency may be increased to tens or even hundreds of megahertzs [1]–[3].

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TABLE I State of the Art of MicroInductor Technology Implemented in a DC/DC Converter

With such high frequencies the value of inductance needed is quite low (<200 nH), which may allow the possible integration of the inductor with the converter IC. The eventual aim of significantly increasing the switching frequency would be the achievement of the complete power-supply-on-chip (PwrSoC). However, an intermediate step toward this is the integration of the passives in package with the active components, i.e., a power-supply-in-package (PSiP). It should also be noted that several recent dc/dc converter products have included integration of the inductor into the same package as the active components. Notable steps toward monolithic integration include the work of Nakazawa et al. [4], which reported a converter IC with a monolithically integrated magnetic-core inductor, switching at 3 MHz and with a size of 16 mm². However, this inductor was still relatively large due to the significant inductance value (0.96 μ H) required for the frequency of 3 MHz. Significant size reduction can be achieved by increasing the switching frequency further, and recently, Bergveld et al. [3] integrated a $1.3 \text{ mm} \times 1.3 \text{ mm}$, 20-nH air-core inductor and a 75-nF capacitor on the same die, to which they flip-chip attached the active component die, so enabling a system-in-package (SiP) application. This converter was demonstrated with a range of switching frequencies up to 100 MHz.

The use of magnetic-core inductors, as opposed to coreless inductors, has the advantages of increased inductance per unit area and containment of magnetic fields, with the disadvantages of extra loss incurred in the magnetic core, especially as the frequency is increased. Current state of the art for magnetic microinductors, as tested in dc/dc converter applications, is given in Table I [4]–[11].

In general, the lower switching frequency of most of the converters reported to date has required relatively large inductances, and hence inductors of relatively large size. Exceptions to this are the work of Prabhakaran *et al.* who demonstrated the use of

| Author | Freq | L | Conv. | Inductor |
|-----------------|-------|------|-------|----------------------|
| | (MHz) | (µH) | Eff. | Area |
| Kowase '05 | 1.0 | 0.14 | 80.0% | 225 mm^2 |
| Kim '01 | 1.2 | 1.6 | 80.0% | 78 mm ² |
| Kim '02 | 1.8 | 1 | 81.0% | 25 mm^2 |
| Park '03 | 2.2 | 2.3 | 75.0% | 65.55mm ² |
| Nakazawa '00 | 3.0 | 0.96 | 81.9% | 16 mm^2 |
| Sato '00 | 5.0 | 0.36 | 82.0% | 36 mm^2 |
| Prabhakaran '05 | 5.0 | 0.01 | 78.0% | 9.02 mm^2 |
| O'Donnell '08 | 20.0 | 0.1 | 67.0% | 6.4 mm^2 |

four 2.6-nH inductors in series in a converter at 5 MHz [11]. The total inductance was still only 10.4 nH and the converter achieved a 78% efficiency, excluding the gate-drive losses. Also, the output current of the converter at 5 A is quite high and would require a smaller inductance than most low-power switching converters. The work by O'Donnell *et al.* [5] demonstrates a relatively small (6.4 mm²) microinductor in operation in a 20-MHz converter. The maximum efficiency of the microinductor in the converter in this case was estimated to be approximately 93%.

In general, if microinductors are to be successfully integrated in dc/dc converters then their size must be small and comparable to the size of the active components, and consequently, they must be capable of operation at high frequencies. Moreover, as standard discrete inductors provide the benchmark for inductor performance, it is important to understand the performance of the microinductor in comparison with discrete inductors. This paper investigates the operation of a microinductor in a 20-100 MHz dc/dc buck converter. We also compare the performance of the fabricated inductor to commercially available wirewound magnetic-core and air-core inductors. The microinductor device design and fabrication are described in Section II. Inductor performance characteristics are described in Section III. Section IV highlights measurement results for the microinductor and discrete inductors when used with a prototype highfrequency dc/dc down-converter IC. Conclusions and future developments are presented in Section V.

II. DEVICE DESIGN AND FABRICATION

There are several figures-of-merit (FoM) that can be used to define the performance of an inductor. These include the quality factor, the inductance enhancement achieved by the core, and the inductance-to-dc-resistance ratio. For an inductor used in a dc/dc converter, none of these are entirely satisfactory. For example, the quality factor gives the ratio of inductive impedance to ac resistance, but gives no indication of dc loss. This is similar for the inductance enhancement or inductance per unit area. The inductance-to-dc-resistance ratio is an important consideration for power inductors, but alone it does not give an indication of ac loss. In order to design the microinductor for dc/dc-converter operation, we therefore choose inductor efficiency defined as

$$\eta_{\rm ind} = \frac{P_{\rm out}}{P_{\rm out} + P_{\rm ind}}$$

where $P_{\rm out}$ is the converter output power and $P_{\rm ind}$ is the total inductor loss, as the FoM to maximize. The objective of the inductor design is, therefore, to maximize inductor efficiency with a given footprint area and with given technology parameters. The inductor loss includes winding and core loss, evaluated for the inductor current waveform, which will be encountered in the converter for the given converter operating conditions.

The inductor structure used is the traditional racetrack design with a magnetic core, as shown in Fig. 1. The coil consists of electroplated copper, which can be deposited to a maximum thickness of 50 μ m. The magnetic material used is Ni₄₅Fe₅₅ alloy, which has a resistivity of 45 μ Ω/cm. The thickness of the

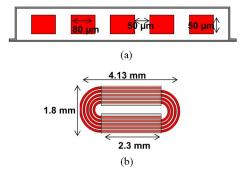


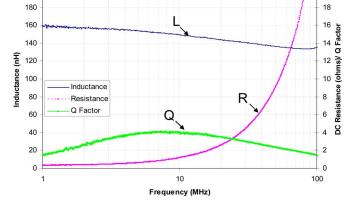
Fig. 1. (a) Cross section and (b) plan view of microinductor used in study. TABLE II CONVERTER AND INDUCTOR TECHNOLOGY PARAMETERS

| Converter Specification | Values | | |
|--------------------------|----------------------|--|--|
| Input Voltage | 1.8 V | | |
| Output Voltage | 1.12 V | | |
| Operating Frequency, MHz | 20 – 100 MHz | | |
| Load Current | 10 – 100 mA | | |
| Inductor Specifications | | | |
| No. of Turns | 5 | | |
| Area | 7.48 mm ² | | |
| Winding Width | 80 µm | | |
| Spacing | 50 μm | | |
| Winding thickness | 50 µm | | |
| Core Length | 2.3 mm | | |
| Core Thickness | 4.2 μm | | |
| Device Length | 4.13 mm | | |
| Device Width | 1.8 mm | | |
| Device Profile | 0.17 mm | | |

layer of magnetic material is determined by the design, and is generally limited to less than 10 μ m due to considerations of limiting the eddy current loss.

In previous work, the authors have developed an analytical model to design the microinductors [12]. This model can accurately predict the inductance, winding loss, and eddy and hysteresis loss of the magnetic material, given the inductor geometry and material parameters. This model is implemented in an optimization routine that varies the inductor geometrical parameters so as to maximize inductor efficiency for the given converter specifications. A range of inductors were designed using this approach for the general converter specifications given in Table II later.

The microfabricated inductor consists of a single layer of racetrack-shaped copper winding (five turns) sandwiched between two layers of magnetic material deposited by electroplating. The details of the inductor fabrication process have been previously described in [12]. From the range of inductors designed and fabricated a 150-nH inductor was chosen for testing with the converter, because it displayed the best L/R ratio for



20

Fig. 2. Measured inductance (in henries), resistance (in ohms), and *Q*-factor versus frequency (in megahertzs) for the fabricated microinductor.

the range of fabricated devices. The dimensions of this inductor are also given in Table II.

The IC-fabrication-compatible process developed by the authors here allows fabricating inductors onto the same substrate or even directly on top of the power management IC to realize a truly monolithic dc/dc converter without the need for postprocessing packaging.

III. INDUCTOR CHARACTERISTICS

After fabrication, the small-signal characteristics of the inductor were measured using the R&S Vector Network Analyzer, ZRVE. In order to do these measurements, the inductor was connected to a substrate with high-frequency coaxial connectors using wire bonds. The resistance and inductance were measured from 1 to 100 MHz. Note that this measurement includes the effect of the wire bond and substrate interconnect. A separate measurement of the wire bond and interconnect showed that these connections have an inductance of 10-15 nH and a resistance of approximately 250 m Ω . In the tests with the converter, wire bonding is also used to connect the inductor; thus, including the wire-bond resistance and inductance gives a realistic picture of the inductance and resistance seen in the converter. The measured inductance, resistance, and quality factor are shown in Fig. 2. The inductance characteristic from the graph has a relatively flat frequency response up to 30 MHz. The measured inductance at 10 MHz is approximately 150 nH and the measured resistance is 1 Ω .

When used in the converter, the inductor current waveform will have a dc component. It is therefore important to measure the inductance-versus-dc-bias-current characteristic for the inductors to determine the dc-handling capability. The current-handling ability of the inductor has been measured at 20 MHz using a HP 4285A LCR Meter with an HP 42841A current source. The dc-bias characteristic shows a small reduction in inductance up to 0.5 A. Note that in this case the inductance is less than obtained with the network-analyzer measurement because the device is measured directly without wire bonds, due to the low current-handling capability of the wire bonds. As the tests in the converter in this study are at an output current of

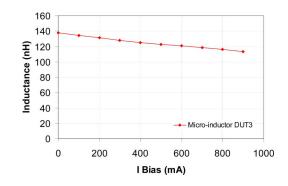


Fig. 3. Measured inductance of microinductor (in nanohenries) versus bias current (in milliamperes).

approximately 70 mA, saturation of the microinductor should not be an issue.

IV. PERFORMANCE IN 20- TO 100-MHZ BUCK CONVERTER

Next, the microinductor has been tested in a high-frequency converter with switching frequencies from 20 to 100 MHz. The dc/dc buck converter was manufactured at NXP in a 0.18-µm CMOS process and converts an input voltage of 1.8 V down to an output voltage that is programmable between 0 and 1.8 V through a 6-bit digital duty-cycle code. For analysis purposes, the switching frequency has been made externally programmable through a variable resistor on the printed circuit board (PCB). A simple form of zero-voltage switching (ZVS) has been implemented to reduce switching losses. More details of this converter have been described in [3]. In fact, the converter IC used in this paper only contains the active die including power switches, drivers, and pulsewidth modulator (PWM). The same active die was also used in an SiP with the LC filter integrated in a passive die, as described in [3]. The optimum output current is 70 mA for ZVS operation, and this is the output current setting that we use in the comparison. The optimum current in ZVS operation depends on the switching frequency used. Bergveld et al. [3] found that an optimum current of 70 mA holds at a frequency of 100 MHz for a 20-nH inductor, which results in a rather large ripple current. For a larger inductance, as considered in this paper, the optimum current decreases at the same frequency. So, for 100 MHz, the optimum output current would drop to values below 70 mA. If the inductance can be increased by a factor of 7, the frequency can be decreased with roughly the same factor giving roughly the same optimum current. In our case, this suggests that for the 150-nH microinductor, the optimum current of 70 mA is valid at the lowest frequency, i.e., 20 MHz.

In order to connect the inductor to the converter IC, a test PCB was designed to enable the high-frequency measurements of the converter and the microinductor, see Fig. 4. The inductor is connected to the PCB with a wire-bond connection.

The test PCB allows for the measurement of the inductor current, which can be used to determine its actual inductance in the converter, verify whether or not the converter is in ZVS operation and determine inductor efficiency. To measure inductor current a 1- Ω SMD sense resistor was placed directly next

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Fig. 4. Tyndall microinductor mounted on the ZVS buck-converter test PCB (IC not mounted on picture).

to the output filtering capacitor. The inductor current was measured differentially across the sense resistor using an FET probe and a digital oscilloscope. Single-ended voltage measurements at each side of the 1- Ω sense resistor were taken, stored, and subtracted for this purpose using the same trigger signal for both measurements. To verify the value of inductance of the microinductor in circuit, we calculate

$$V = L\frac{di}{dt}.$$
 (1)

Taking the rising and the falling slopes of the inductor current, the inductance was measured to be 166 nH at 20 MHz in ZVS operation, which correlates quite closely to the design value of 150 nH.

As part of the tests, the performance of the fabricated inductor was compared to commercially available wire-wound chip inductors from Coilcraft. The chip inductors chosen for the comparison are a 0402AF-141 [13] 140-nH magnetic-core inductor and a 0805HS-151 [14] 150-nH air-core inductor. The 0402AF magnetic-core chip inductor is 0402 chip size (1.12 mm \times 0.66 mm) and is 0.66 mm thick. The 0805HS air core is the standard 0805 chip size (2.16 mm \times 1.52 mm) and is 1.45 mm thick.

Fig. 5 displays the measured inductance and resistance characteristics of the three technologies in the comparison. As we can see from the figure, the three inductors are relatively similar in inductance value up to 20 MHz. The air-core inductor has, however, a flatter inductance profile than either of the magneticcore inductors indicating that the inductance contribution of the magnetic material decreases with frequency. The self-resonant frequency (SRF) of both the chip inductors is greater than 1 GHz, whereas for the microinductor the SRF is approximately 300 MHz, which indicates considerably higher parasitic capacitance in the case of the microinductor. The curves also show that the resistance of the microinductor increases faster with frequency. A review of the measured resistance and inductor areas for the three models in the comparison is given in Table III.

A. Measured Efficiencies of the Converter With the Inductor Technologies

The measured efficiencies of the ZVS buck converter with the three inductor technologies are shown in Fig. 6. Efficiency is

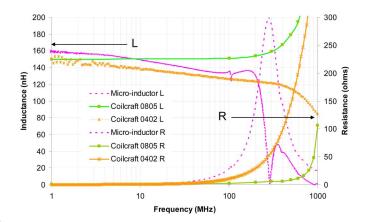


Fig. 5. Measured inductance (in henries) and resistance (in ohms) as a function of frequency (in hertzs) of the three inductor technologies in the comparison.

measured at 70 mA output current and from 20 to 100 MHz. The converter input voltage was 1.8 V and the converter output voltage was approximately 1.12 V for the converter efficiency tests. The difference in converter maximum efficiency between using the commercially available chip inductors and the microinductor is approximately 2%. When using the microinductor, converter efficiency is approximately 78.5% at 20 MHz.

The efficiency measurements versus dc output current for the ZVS converter were taken from 10 to 100 mA at a 20 MHz switching frequency. Again, we compared the three different inductors by their performance in the converter. The input voltage for all measurements was 1.8 V, the duty cycle was fixed at 62%, and the output current was varied from 10 to 100 mA. Fig. 7 shows the obtained results. The microinductor performance again is slightly lower than the wire-wound inductors. Some of this is due to the effect of increased power loss from the added resistance of the wire bonds, which is analyzed in the next section.

B. Analysis of Converter Losses

Power loss for the converter can be divided into three main categories—switching, ohmic, and inductor loss, assuming other losses are negligible in ZVS operation. The total converter power loss is given by

$$P_{\text{loss_converter}} = P_{\text{sw}} + P_{\Omega} + P_{\text{ind}}.$$
 (2)

The switching loss is assumed to be entirely due to losses associated with parasitic capacitances, and hence can be expressed as

$$P_{\rm sw} = fCV^2 \tag{3}$$

where V is the input voltage and C is an effective capacitance. The value of this effective capacitance can be determined by measuring the losses versus frequency at no load. To measure this switching loss of both power switches, P_{sw} , the load and *LC* filter were removed from the circuit and the input power was measured versus frequency. This input power is inclusive of the driver and PWM modulator power consumption. Losses due to dead time in ZVS operation are not included since the output current is zero, but are assumed to be small. The measurement

| Inductor | Area (mm ²) | $R_{dc}(\Omega)$ | $R(\Omega)$ at 20 MHz |
|------------------|-------------------------|------------------|-----------------------|
| Micro-inductor | 7.48 | 0.191 | 3.5 |
| Coilcraft 0805HS | 2.5 | 0.560 | 0.780 |
| Coilcraft 0402AF | 0.5 | 0.260 | 1.45 |

TABLE III Measured Resistance of Three Inductor Models in Study

was performed with the duty cycle set to 62% and $V_{\rm out}$ set to 1.12 V. From this measurement, the effective capacitance was estimated to be 90 pF.

The ohmic loss of the converter P_{Ω} was measured including the filter circuit, but subtracting the effect of the inductor resistance. The ohmic losses are given by

$$P_{\Omega} = I^2 R \tag{4}$$

where I is the current being drawn from the input supply source and R is the equivalent converter resistance, which is determined by plotting the imposed output current against the measured resulting output voltage of the converter. Since no internal control loop has been provided for on the IC, the output voltage will drop when the output current is increased. The equivalent converter resistance R can then be inferred from the slope of the resulting curve, after which the inductor resistance is subtracted. From this measurement, the equivalent resistance of the converter excluding the inductor was estimated to be 1.5 Ω . Once P_{sw} and P_{Ω} were evaluated, these values were added and the sum was subtracted from the total measured power loss. The resultant value is assumed to be the approximate measured power loss across the inductor P_{ind} .

The overall measured converter loss, simulated inductor loss $P_{\rm ind}$, and total converter loss obtained by adding the simulated $P_{\rm ind}$ value to the ohmic loss P_{Ω} and switching loss $P_{\rm sw}$ inferred from measurements at a 20-MHz switching frequency for 10-100 mA output current is shown in Fig. 8. Equations (3) and (4) have been used to infer P_{sw} and P_{Ω} from the total measured losses, respectively. Microinductor loss Pind was simulated using a frequency-dependent lumped equivalent circuit model of the inductor using a PSpice simulation of converter conditions for which the duty cycle was set to 62% and $V_{\rm out}$ was set to 1.12 V. At 20 MHz, it is evident that the switching and ohmic losses inferred from the measurements of the converter loss dominate at higher current when compared to inductor loss. In fact, the switching losses P_{sw} stay fixed with constant frequency, according to (3). However, the ohmic losses P_{Ω} increase with increasing output current, as given in (4).

From Fig. 8, it is evident that the measured overall converter power loss with both inductors is somewhat higher than the values obtained from (3) and (4) combined with simulated inductor loss. This is caused by dead-time losses, which are not taken into account in P_{sw} and P_{Ω} , but do occur in the measured overall losses.

Fig. 9 compares the inductor efficiencies inferred from measurements and those obtained from the inductor simulation for the ZVS converter with the microinductor and the Coilcraft 0402AF inductor. The converter operated again at 62% duty cycle and at an output current of 70 mA.

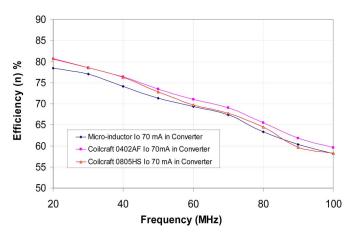


Fig. 6. Measured converter efficiency (in percentage) versus frequency (in megahertzs) for the three inductor technologies at 70 mA output current.

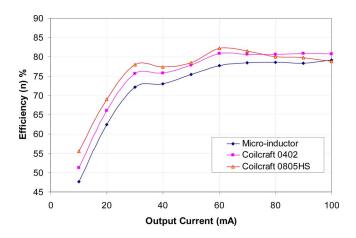


Fig. 7. Measured converter efficiency (in percentage) versus output current (in milliamperes) for the three inductor technologies at 20 MHz switching frequency.

The additional bond-wire effect of the microinductor adds additional dc resistance, and so reduces the overall converter efficiency. Fig. 9 also displays the improvement of the microinductor efficiency when the wire bonds are removed from the efficiency calculation. The inductor efficiency curves are consistent with the measured converter efficiency curves, in that the efficiency of the microinductor is shown to be 2%-3% lower than the chip inductors. The peak microinductor efficiency is approximately 93%, excluding the effects of the wire bonds.

For the microinductor, the loss can be examined in terms of the split between the winding loss (ac and dc) and the core loss. Fig. 10 shows a loss breakdown model of the microinductor for a load current of 100 mA, obtained from the inductor simulation model. This shows that the eddy current loss in the core material contributes 43% of the total losses of the microinductor.

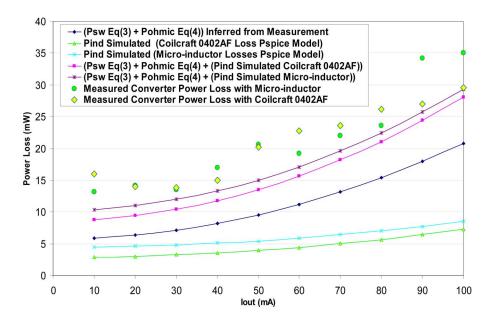


Fig. 8. Measured and simulated converter and inductor loss (in milliwatts) at 20 MHz switching frequency for 10–100 mA output current.

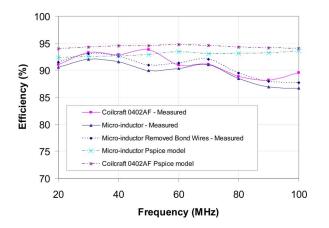


Fig. 9. Measured and simulated inductor efficiency of microinductor and Coilcraft chip inductor (in percentage) versus frequency (in megahertzs) when used in the ZVS buck converter.

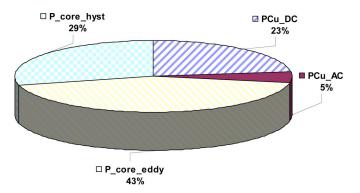


Fig. 10. Breakdown of losses in the microinductor for 100 mA dc output current and at a switching frequency of 20 MHz.

V. CONCLUSION

This paper has presented the design and measurement of a microinductor for use in a 20–100 MHz dc/dc converter. The

microinductor has been shown to have a peak efficiency of 93% at 20 MHz and is approximately 2% less efficient than the equivalent magnetic and air-core chip inductor equivalents.

Even though microinductor efficiency is slightly below commercial chip alternatives, the difference in performance in the converter is small. From an analysis of the losses in a microinductor from 1 to 100 MHz, it is clear that both winding and core loss need to be further reduced. The winding loss is mainly due to the copper dc resistance and loss in the core is due to eddy current loss. The winding loss could be decreased by making the copper winding thicker and the core loss could be decreased by the addition of laminations to reduce the path area of circulating eddy currents [15].

With such a small difference in inductor performance from the study, one looks at the possible advantages of magnetic microinductors over chip alternatives. The profile of the microinductors is relatively low at 0.17 mm when compared to 1.45 mm of the 0805 air-core inductor and 0.66 mm of the 0402 magnetic-core inductor. This low profile may benefit packaging requirements to facilitate a complete SiP device. However, the microinductor still has quite a large area of 7.48 mm² compared to the smallest chip inductor that has an area of just 0.5 mm². If microinductor technology is to compete with chip inductors, device area must still be reduced substantially. Future microinductor devices will target a smaller surface area and an increased inductance per unit area. For future converter IC integration, low profile and small area of the microinductor will be necessary to facilitate a stacked-die solution or total integration on the silicon substrate. There is also the possibility to combine the microinductor technology with integrated-capacitor technology on a single die, which is beneficial when considering high-frequency dc/dc converters. Shorter high-frequency current loops would increase overall converter efficiency and reduce electromagnetic interference (EMI) problems, when compared to using external SMD passive devices.

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